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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/540,720	01/13/2006	Koichiro Kishima	450101-04870.1	2419
William Fromn	7590 08/13/2007		EXAM	INER
Frommer Lawrence & Haug			NHU, DAVID	
745 Fifth Aven New York, NY	•		ART UNIT	PAPER NUMBER
11011 1011,111	,		2818	
			MAIL DATE	DELIVERY MODE
			08/13/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
		10/540,720	KISHIMA ET AL.			
	Office Action Summary	Examiner	Art Unit			
		David Nhu	2818			
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet wi	th the correspondence address			
WHIC - Exter after - If NO - Failu Any i	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. operiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNIC 36(a). In no event, however, may a reviil apply and will expire SIX (6) MON 1, cause the application to become AB	CATION. Peply be timely filed THS from the mailing date of this communication ANDONED (35 U.S.C. § 133).			
Status			•			
1)[Responsive to communication(s) filed on <u>02 Oc</u>	ctober 2006.				
2a) <u></u> □	This action is FINAL . 2b)⊠ This	action is non-final.				
3)	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D	. 11, 453 O.G. 213.			
Dispositi	on of Claims					
4)⊠	Claim(s) <u>1-20</u> is/are pending in the application.					
	4a) Of the above claim(s) is/are withdrawn from consideration.					
5)	Claim(s) is/are allowed.					
6)	Claim(s) is/are rejected.					
7)	Claim(s) is/are objected to.					
8)⊠	Claim(s) <u>1-20</u> are subject to restriction and/or e	election requirement.				
Applicati	on Papers					
9)[]	The specification is objected to by the Examine	•				
	The drawing(s) filed on is/are: a) ☐ acce		v the Examiner			
,,,,	Applicant may not request that any objection to the					
	Replacement drawing sheet(s) including the correcti			(d)		
11) 🔲	The oath or declaration is objected to by the Ex		-	ω,.		
	inder 35 U.S.C. § 119					
	•	priority under 25 U.C.C. C	440(-) (-) (-)			
_	Acknowledgment is made of a claim for foreign ☐ All b) ☐ Some * c) ☐ None of:	priority under 35 U.S.C. 9	119(a)-(u) or (1).			
1. ☐ Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage						
	application from the International Bureau	-	Toostroe in this National Stage			
* S	see the attached detailed Office action for a list of	· · · · · ·	eceived.			
		•				
		No.	ZIRZ/			
Attachment	t(e)	2 -				
	e of References Cited (PTO-892)	4) Interview S	ummary (PTO-413)			
2) Notic	e of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Date	•		
	nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	5) Notice of In	formal Patent Application			

Election/Restrictions

1. Restriction to one of the following inventions is required under 35 U.S.C. 121:

Group I: Claims 1-7, 11-17, draw to a method for fabricating a semiconductor substrate, classified in class 438, and subclass 513

Group II: Claims 8-10, 18-20, draw to a semiconductor substrate, classified 257, and subclass 760.

- 2. Inventions I and II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case unpatentability of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by the processes /method materially different from those of the group II invention. For example, claim 1, 11, a heat treatment step of forming a silicon dioxide layer in he single crystal silicon.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a petition under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Art Unit: 2818

5. Any inquiry concerning this communication on earlier communications from the examiner should be directed to David Nhu, (571)272-1792. The examiner can normally be reached on Monday-Friday from 7:30 AM to 5:00 PM.

The fax phone number for the organization where this application or proceeding is assigned is (571)273-8300.

David Nhu

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August 7, 2007

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